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Dielectric metasurface based high-efficiency polarization splitters

Zhongyi Guo,^{*a} Lie Zhu,^a Fei Shen,^a Hongping Zhou^a and Rongke Gao^{*b}

In this paper, a novel polarization splitter has been designed at the telecommunication wavelength of 1500 nm successfully based on the dielectric metasurface consisting of a silicon nanobrick array, which can generate two different wavefronts for two orthogonal input polarizations with well over 90% transmitted efficiency by exactly selecting the sizes of the used nanobricks. The splitting mechanism is attributed to the fact that the used nanobricks can supply two different incremental transmission phases for the X-linear-polarization (XLP) incidence and Y-linear-polarization (YLP) incidence respectively. A polarization-dependent beam splitter which can effectively deflect the X- and Y-linear-polarization incidences in the opposite direction with 90% transmitted efficiency have been realized based on the same metasurface, where the refracted angle of the co-polarized refracted light can be arbitrarily controlled by changing the lattice constant of the nanobricks. In addition, a polarization-independent beam deflector which can make the linear-polarization (XLP and YLP) incident lights refract in the same direction has also been designed and presented. However, it is very difficult to obtain concrete XLP and YLP compositions in the transmitted fields in real experiments. Thus we have designed a novel metalens to focus the two orthogonal polarization compositions in different positions. The capacities to completely manipulate the phase and wavefronts demonstrate the potential of the designed metasurfaces in realizing most free-space transmissive optical devices such as phase plates, polarizers, as well as vector beam generators and so on.

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1. Introduction

Recently, full manipulation of light propagation on the nano-scale has attracted lots of attention due to its great functionalities. Compared to conventional optical devices that are restricted by the permittivity for natural materials and mostly optical thickness, metasurfaces can possess arbitrary values of permittivity and thus manipulate the wavefront of light with extreme freedom. Moreover, metasurfaces are the two-dimensional counterpart, which makes them suitable for integration on a photonic chip and mass production. Generally, metasurfaces are composed of an array of resonators with subwavelength spatial resolution, utilizing asymmetric electric dipole resonances to allow for an abrupt change in the amplitude and phase of the impinging light by manipulating the size and shape of the resonators.¹ Based on metasurfaces, recently, plenty of planar optical components have been designed and realized successfully, including optical vortex beam generators,^{2,3} gratings,⁴ lenses,^{5–9} holographic masks,^{10,11} waveplates,^{12,13} and so forth.

By far, a majority of studies have been focused on metallic resonators and their plasmonic properties, however, the metallic metasurfaces possess relatively low transmission efficiency due to the inherent nonradiative ohmic losses at optical frequencies.^{14–18} There are several methods commonly used to improve the transmission efficiency, which include the reflective metasurfaces,¹⁹ Huygens' metasurfaces²⁰ and all-dielectric metasurfaces.^{21,22} However, the reflective metasurfaces only operate in reflection mode with a metal ground plane and can not be applied to the mainstream transmission devices. And the Huygens' metasurfaces are fabricated by three-dimensional structures, which has been hindered in the real fabrications. Dielectric metasurfaces offer one potential solution to control lightwaves at the nanoscale with extremely high transmission efficiency, which originate from that the dielectric nanostructures can be optimized to simultaneously possess both electric and magnetic dipole resonances. Thus, the dielectric metasurfaces can enable high transmission efficiency with a full 2π phase control. Furthermore, the nanometer silicon can be easily obtained by mature technology of semiconductor with low manufacture cost, which makes silicon an ideal platform for high-efficiency metasurfaces. However, most researches about the dielectric metasurfaces have focused on the reflective modes^{23–25} and the major spectral bands of recent researches are the visible regime and near-infrared frequencies.^{26,27}

^aSchool of Computer and Information, Hefei University of Technology, Hefei, 230009, China. E-mail: guozhongyi@hfut.edu.cn

^bSchool of Instrument Science and Opto-electronics Engineering, Hefei University of Technology, Hefei, 230009, China. E-mail: rkgao@hfut.edu.cn

Fig. 1(c) and (e) shows the calculated intensity transmission efficiencies as the functions of the nanobrick dimensions along X - and Y -directions, a and b , with the range from 20 nm to 560 nm, under the XLP and YLP incidences respectively. The corresponding phase variations as the functions of a and b , under the XLP and YLP incidences, are shown in Fig. 1(d) and (f) respectively. As can be seen from numerical simulations results, the metasurfaces can achieve a full 0 to 2π phase variation, and meanwhile the transmission efficiencies can reach to as high as 90%. The higher co-polarization transmission is originating from the lower reflection, nearly no absorption of the silicon nanobricks at the telecommunication wavelength, and the lower polarization conversion. Thus, any desired phase as well as extremely high transmission can be obtained by properly choosing the parameters. Moreover, it is evident from Fig. 1(d) that under the XLP incidence, with the preconditions of keeping the dimension in y -direction unchanged and higher than 200 nm, we can achieve 0 to 2π phase variation by only changing the dimension of nanobrick along X -direction. Analogously, as shown in Fig. 1(f), under the YLP incidence, due to the symmetry of the nanobricks, we can also achieve complete phase control by only changing the brick diameters along Y -direction. The results means that the phases of XLP refraction light (φ_x) and YLP refraction light (φ_y) can be controlled fully by changing the dimensions of nanobrick in x -direction and y -direction, respectively. Thus, any combination of φ_x and φ_y can be simultaneously obtained by appropriately choosing two nanobrick parameters of a and b .

The refraction angle of incident light can be calculated by the generalized Snell's law, which is related to the phase gradient along the interface and can be expressed as follow^{32,33}

$$n_t \sin \theta_t - n_i \sin \theta_i = \frac{\lambda_0}{2\pi} \frac{d\varphi}{dx} \quad (1)$$

where θ_i and θ_t are the incident angle and refracted angle of transmitted light respectively, n_i and n_t is the refractive indexes of the media in the both sides of the interface respectively, λ_0 is the wavelength of light in vacuum and the phase discontinuity $d\varphi/dx$ can be expressed as $2\pi/L$ (L is the length of a supercell).³⁴ It should be noted that each structural unit radiates with a different phase, and then the interference forms a new wavefront with full phase control and maintaining extremely high transmission.

In order to validate the performance of the phase-gradient metasurfaces, a polarization splitter is proposed for generating

The schematic of the designed nanobricks standing on a glass substrate is depicted in Fig. 1(a). The refractive index of the 900 nm thick silicon nanobrick and 200 nm thick SiO₂ are 3.48 and 1.48, respectively. The method of finite-difference time-domain with periodic boundary conditions is used to perform the numerical simulations. Incident plane wave at a fixed wavelength of 1500 nm illuminates to the metasurfaces normally with the linear polarization along the x -axis. Fig. 1(b) clearly shows the corresponding transmission efficiency (T) and reflection efficiency (R) under XLP incidence, as the functions of θ which is the angle between the long axes of the silicon nanobrick and X -axis. The blue solid curves and the blue circular curves represent the transmitted efficiencies of the cross-polarization state ($|T_{\text{cross}}|^2$) and the co-polarization state ($|T_{\text{co}}|^2$) respectively. The red dashed lines and the red circular lines represent the reflected efficiencies of the cross-polarization state ($|R_{\text{cross}}|^2$) and the co-polarization state ($|R_{\text{co}}|^2$) respectively. As depicted in Fig. 1(b), the cross-polarization transmission reaches the maximum when the slant angle of the nanobrick is 45°, nevertheless, the concrete value is still lower than 15%. And the co-polarized transmission remains above 79%, which indicates that there is little polarization conversion, especially at the angle of 0°. In addition, the co-polarized and cross-polarized reflection efficiency remain particularly smaller than 10% and nearly 0%, respectively. Thus

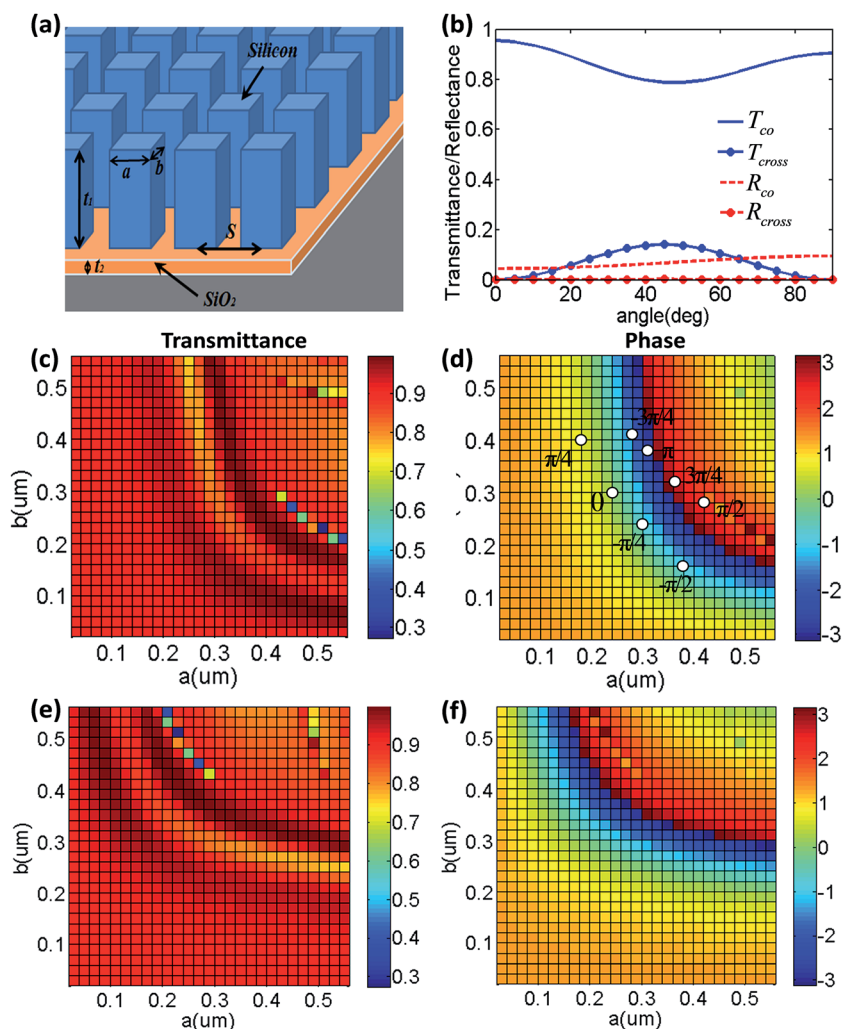


Fig. 1 (a) Schematic of the metasurface with a unit cell period of $s = 650$ nm, $a = 300$ nm, $b = 150$ nm, $t_1 = 900$ nm and $t_2 = 200$ nm, s is the lattice constant. In the simulation, the structured silicon metasurfaces are placed on the glass substrate. (b) The transmission efficiencies and reflection efficiencies of co-polarized light (blue solid lines and red dashed lines) and cross-polarized light (blue circles and red circles) as the function of slant angles (θ), respectively. (c) and (e) transmittance of the nanorods as the function of the setting parameters a and b for the XLP and YLP incidences, respectively. (d) and (f) corresponding phase variations of transmitted light as the function of the setting parameters a and b for the XLP and YLP incidences, respectively.

two different wavefronts with two orthogonal polarizations (XLP and YLP) light at the normal incidences. Here, 8 nanobricks have been chosen in a supercell with a phase increment of $\varphi = \pi/4$, in which there will be a phase variation of 0 to 2π for the XLP incidence, but a phase variation of 2π to 0 for the YLP incidence. Therefore, the refractive beams can be deflected into different directions and formed two different wavefronts for the XLP and YLP incidences. From Fig. 1(d) and (f), the proper dimensions of 1–8 resonators as shown in Fig. 2(a), can be selected respectively as: (1) $a = 292$ nm, $b = 385$ nm; (2) $a = 240$ nm, $b = 555$ nm; (3) $a = 350$ nm, $b = 160$ nm; (4) $a = 248$ nm, $b = 248$ nm; (5) $a = 160$ nm, $b = 350$ nm; (6) $a = 555$ nm, $b = 240$ nm; (7) $a = 385$ nm, $b = 292$ nm; (8) $a = 340$ nm, $b = 320$ nm.

When a LP wave with the polarized angle of 45° is incident to the designed metasurfaces, the LP wave can be decomposed as the XLP and YLP incidences, and then the whole transmitted fields can be regarded as the superposition of the

corresponding transmitted XLP and YLP lights. As depicted in Fig. 2(b), under the 45° LP incidence, the concrete XLP and YLP transmitted electric field distributions can be extracted from the whole transmitted fields, which demonstrate that the designed device can serve as a polarization beam splitter with a proper successive treatment. It is clear that there exist a well-defined phase front with the refracted angles of -17° and 17° for transmitted XLP and YLP lights respectively, which agree well with the theoretical expectation on the refracted angles of $\pm 16.7^\circ$ based on the eqn (1). As can also be seen from Fig. 2(b), both XLP and YLP wavefronts can transmit from the designed metasurface without being affected by the metasurface, which can further verify that the incident wavefront can transmit from the metasurfaces without reflection.

To further verify the effectiveness of the designed metasurfaces, we have also shown that the refracted angles can be arbitrarily controlled to satisfy our needs by changing the



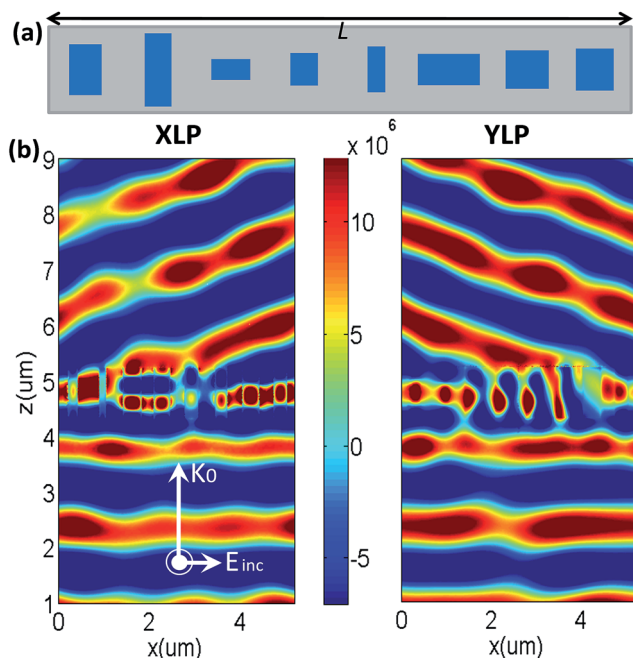


Fig. 2 (a) Schematic of eight resonators that provide a phase shift from 0 to 2π for XLP incidence while conversely changing from 2π to 0 for YLP incidence. (b) The extracted transmitted XLP (left) and YLP (right) electric field distributions of the designed metasurfaces under the normal incidence of 45° LP light at a wavelength of 1500 nm, respectively.

periodical length L of supercell. The periodical length of supercell can be expressed as $L = sN$, where s is the length of the unit cell and N is the number of the used unit cells in one supercell. The desired refracted angles can be modulated by adjusting the length of the unit cell of s and the number of the used unit cells of N when the wavelength is a constant.

Fig. 3(a–d) shows the situation that under the normal LP incidence with the polarized angle of 45° to the designed metasurfaces, the deflected angles are 30° and 60° , respectively,

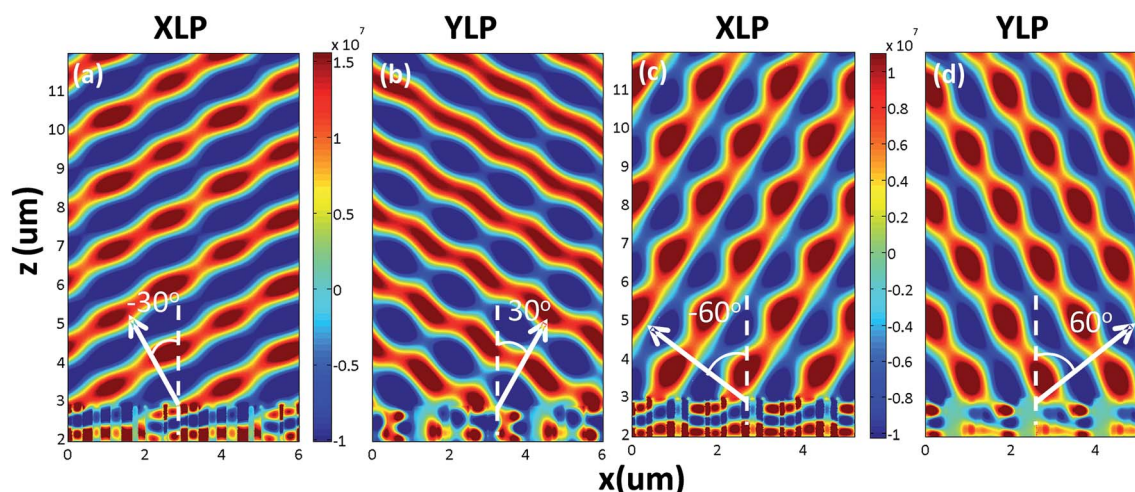


Fig. 3 Transmitted XLP (a and c) and YLP (b and d) electric field distributions of the metasurface illuminated with a normal incidences of 45° LP lights with the refractive angles of 30° (a and b) and 60° (c and d).

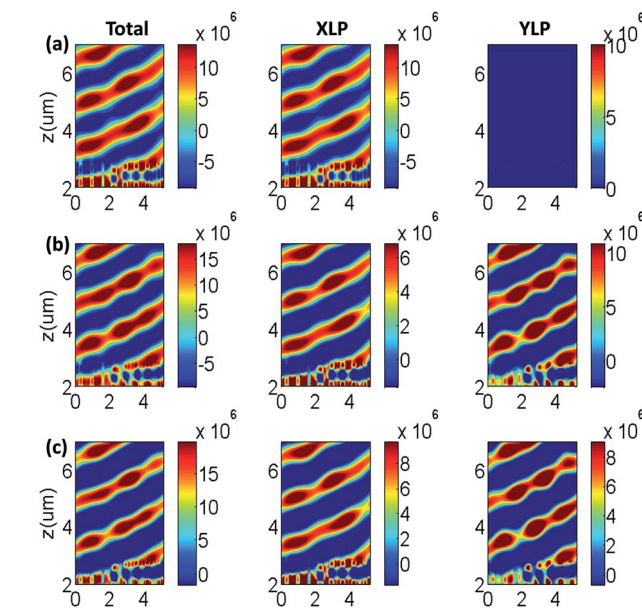


Fig. 4 Transmitted total, XLP and YLP electric field distributions of the metasurface illuminated with normal incidences of XLP light (a), 30° LP light (b) and 45° LP light (c) with the refractive angles of 17° .

which indirectly verify the validity that the designed metasurface can separate the XLP and YLP incidences and deflect the transmitted light to an arbitrary angle. To achieve refractive angle of 30° , the lattice constant s has been reduced to 500 nm and changing the number of the nanobricks N into six. Similarly, when s has been reduced to 433 nm and N changed into 4, the refractive angle of 60° can be obtained. It should be noted here that the relation between the nanobrick dimensions and the phases should be recalculated and reselected correctly to avoid the occurrence of phase errors. As depicted in Fig. 3(a) and (c), the deflected angles of -30° and -60° match well with the theoretical expectations, although the coupling effect between adjacent resonators has been enhanced due to the

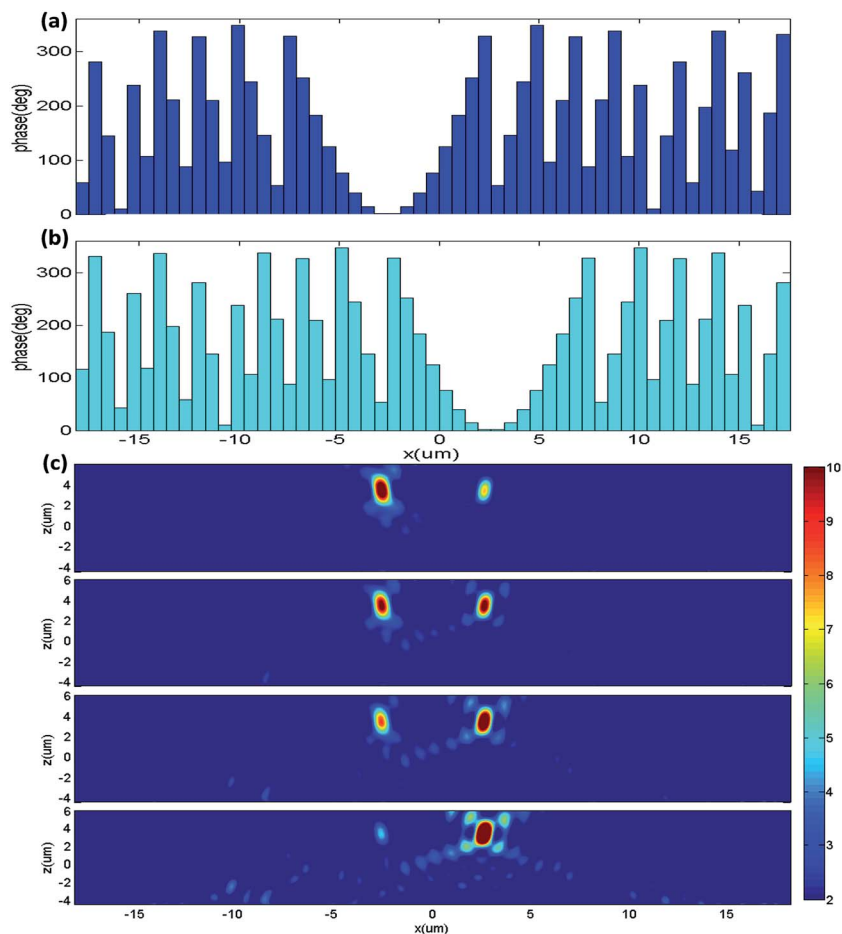


Fig. 5 (a) The required transmitted phase along x-axis when incidenting x-polarized and (b) y-polarized light to realize the function of focus. (c) Transmitted intensity distributions of the metasurface illuminated with a normal LP incidences with polarization-angle of 30°, 38°, 45° and 60°, respectively.

decreasing lattice constant. In consequence, the designed metasurface can separate the XLP and YLP lights to arbitrary directions with extremely high transmission efficiency, which can be applied as a polarizing beam splitter.

All of the above simulations are polarization-dependent, in which different polarization incidences will be refracted into different directions. In order to further verify the manipulating capability of the designed metasurfaces, here, we will propose a special polarization-independent device that can deflect XLP and YLP incidences to the same direction. Similar as the above, we can find a series of unit cells with a proper dimensions, which possess the same phase variations for the XLP and YLP incidences respectively. By numerical simulations, the 8 unit cells with the phase variations ranging from 0 to 2π with an increment of $\varphi = \pi/4$ for the XLP and YLP incidences simultaneously can be found from Fig. 1(d) and (f). Under the normal incidence of XLP light, the extracted transmitted XLP and YLP compositions have been shown in Fig. 4(a). The total transmitted electric field distributions of the metasurface are the same as the transmitted XLP electric field distributions and there is no transmitted YLP electric field due to the zero cross-polarized conversion. Fig. 4(b) and (c) show the transmitted electric field distributions with

normal incidences of 30° LP light and 45° LP light, respectively. Because the two different polarizations have the same phase discontinuity of $d\varphi/dx$, the XLP and YLP compositions of the incident beam will be refracted to the same angle of 17° as the same as the above result. Furthermore, it is observed that with increasing the incident polarization-angle, the transmitted XLP electric field clearly increases while the transmitted YLP electric field decreases accordingly. Similarly, an arbitrary refraction angles can be obtained by changing the lattice constants and number of the nanobricks. As shown in Fig. 4, the total transmitted electric field distributions with normal incidences of the XLP light, 30° LP light and 45° LP light are nearly identical and these three different polarization incidences have the same deflection angle of 17°, which verify that the designed device can serve as a beam deflector to redirect the incident lights to the same angle regardless of the incident angle of polarization.

Although we can extract the concrete XLP and YLP compositions of the transmitted fields in theory, it is very difficult to obtain them in experiments if there is no any further treatments. Therefore, here, we will try to design a novel metalens to focus the XLP and YLP compositions in different positions, which can separate the XLP and YLP compositions in the transmitted fields



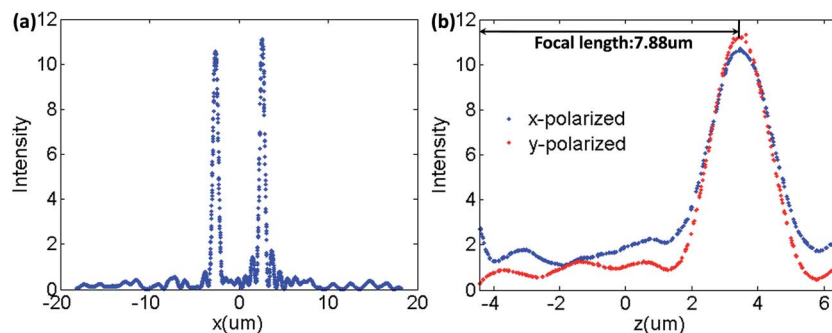


Fig. 6 (a) The electric field intensity along the x-axis and (b) the z-axis at the focal plane.

effectively. The metalens with the focusing point in the XOZ plane can be designed by controlling the transmitted phase which follow the hyperboloidal profile^{5,6,35}

$$\varphi = \frac{2\pi}{\lambda} \left(\sqrt{x^2 + f^2} - f \right) \quad (2)$$

where f is the focal length of the metalens and the phase φ can be easily obtained by simple geometrical arguments. The focusing ability of the metasurface is evaluated by the numerical aperture $NA = \sin[\tan^{-1}(D/2f)]$, where D is the width of the metalens.

Here, we set the focal length of the metalens as 8 μm , and the focusing points for XLP and YLP components lies in the both sides of Z axis in the XOZ plane, which means the position of the focusing points for XLP and YLP components are set as $(-2.6 \mu\text{m}, 0, 4 \mu\text{m})$ and $(2.6 \mu\text{m}, 0, 4 \mu\text{m})$. The concrete calculated phase distributions of the designed metalens for XLP and YLP components have been shown in Fig. 5(a) and (b) respectively. Thus, based on Fig. 1(d) and (f), the length and width of nanobricks corresponding to the desired phases in different position can be obtained to design the metalens. The two desired phases are symmetry about the focusing positions and independent of each other for two orthogonal input polarizations. The focal length defined as the distance between the metalens and the focusing spot is 8 μm at the wavelength of 1.5 μm . As depicted in Fig. 5(c), the designed metalens can focus the XLP and YLP incidences into the upper-left and upper-right spots of the refractive field, respectively. The intensity maps for different polarization angle of 30°, 38°, 45° and 60° are given in Fig. 5(c) respectively. It can be clearly observed that the focusing intensities of the XLP component are getting smaller with increasing the incident polarization-angle. Because the incident intensity component along x-axis is getting smaller when the incident polarization-angle is getting larger, especially the focusing intensities of two different polarization states are nearly the same when the incident angle is 38°. It should be noted that the incident energy components along x- and y-axis are the same for the incident polarization-angle of 45°. Nevertheless, the focusing intensity for y-polarization component is stronger, which is due to the transmission efficiency for x-polarization component is slightly smaller than that for y-polarized component.

For quantitatively analyzing the focusing effect of the designed metalens, the co-polarized electric field intensity along the x-axis and the z-axis at the focal plane for the designed

metalens are presented in Fig. 6(a) and (b) respectively. The simulated focal length is slightly smaller than the theoretical prediction, which may be due to the weak coupling between the nearby nanobricks in the simulations. Furthermore, the corresponding FWHMs along the x-direction at the focal plane for the two orthogonal input polarizations are 720 nm and 647.5 nm, which indicate that the designed metalens work in relatively high qualities. The depths of focus (FWHM along the z-direction) are 2.38 μm and 2.12 μm , respectively. And the numerical aperture is about 0.9 (the focusing spots are quite small), which is larger than most of the previous works³⁶ and verifies the better focusing efficiency of our designed metalens. Furthermore, the focusing position can be arbitrary controlled in the focusing plane by changing the phases.

3. Conclusion

In summary, we have demonstrated dielectric gradient metasurfaces consist of periodic arrangement of differently sized silicon nanobricks, which can refract the input light with full 0 to 2π phase control and extremely high efficiency (over 90%) at telecommunication wavelength. The designed metasurfaces can simultaneously achieve two different wavefronts for different incident LP light by exactly selecting the long axis and short axis of the nanobricks. Thus, a novel polarization splitter that separates two orthogonal input polarizations to arbitrary different directions and a beam deflector with polarization independence based on the designed dielectric metasurfaces have been demonstrated. Our demonstrated optical metalens with polarization selectivity can be helpful to obtain the concrete XLP and YLP compositions of the transmitted fields in experiments. Our designs will find a large amount of practical applications with high efficiency, such as antireflection coatings, phase modulators, the vortex converter, and so forth.

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